

# New Release

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# IGBT power module(750V): BYD (equipped in ATTO 3) BG820F08B14L5 Module & IGBT Structure Analysis Report



https://www.byd.com/jp/car/atto3



Module appearance



IGBT die

#### **Overview**

BYD, China's largest EV (electric vehicle) manufacturer began selling the ATTO 3 in China in February 2022.

The ATTO 3 is equipped in a 58.56 kWh battery and can travel 485km.

It has also been on sale in Japan since January 2023 as an EV passenger car for the Japanese market.

This report is a structure analysis report that clarifies the details of the IGBT power module equipped in the "ATTO 3" inverter and the IGBT mounted in the module.

#### **Product features**

- Product number: BG820F08B14L5 750V Si-IGBT IC = 820A
- Product release data: 2022
  URL: <a href="https://www.bjxchip.com/web/soft/bg820f08b14l5.pdf">https://www.bjxchip.com/web/soft/bg820f08b14l5.pdf</a>
- Module equipped in ATTO 3 motor 150kW (system voltage 390V)
- IGBT uses 750V trench and field stop technology
- Module current capacity(Ic=500A:TF=65 $^{\circ}$ C, Tvj=150 $^{\circ}$ C, Ic=820A:TF=25 $^{\circ}$ C, Tvj=175 $^{\circ}$ C)
- The current density is 3.4 A/mm<sup>2</sup>.

#### **Report Contents**

#### 1. Module structure analysis report (35 pages)

- An external thermistor is used as the temperature detection element, and no temperature sensor diode is formed into the chips.
- Aluminum oxide DBC substrate is used for the insulating layer.

#### 2. IGBT structure analysis report (76 pages)

- Trench type IGBT, 1-phase Si-IGBT(4 dies) and Si-FWD (3 dies).
- Cell pitch, trench width and depth are the same as those of Infineon EDT2 using a micro-trench process.
  - \* The trench bottom shape is distinctive. (This is confirmed in products of Chinese manufacturers)
- Due to issues with the size of the contact diameter and trench width, electrode extraction pads are used.

#### Report price

Delivered one week after order placement. Please contact us for report pricing.



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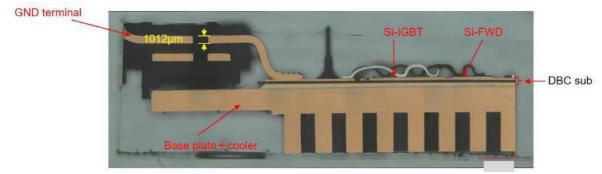
# 1. Module structure analysis report

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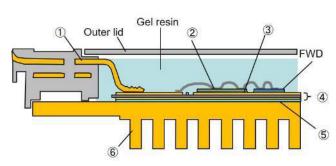
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## **Excerpt from Module structure analysis report**



**Module cross-sectional OM image** 



4	SHIGHT			
2-1	VS 75237570000	Bonding wire	#175um	M .
2-2	- 3	Protective film	7:4~9.5pm	-0.0
2-3	Į,	Substrate	Mun	50
2-4		Backside metal-1	Short	ACH
2-5		Backside metal-2	145 mm	n n
2-6		Backside metal-3	Minn	N N
3	Die atta	ch(IGBT)	M. Jun	SmigGa
4	DBC sub	)		-
4-1	8	DBC upper electrode	29961	01
4-2		Insulating substrate	\$15pm	#6304 (2h)
4-3		DBC bottom electrode	Hlam	Ca
5	Solder	· ·	Illum	3HACK
6	Cooler		\$135pm	
6-1		Ni plating layer	i-lum.	- 6
6-2	-	Ni-P plating layer	6.Euro	50-8
6-3		Base plate	5445µm	01
6-4		Cooling pin	SHRun	Ga
7	Case			COLUMNS

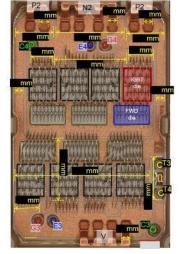
Length measurement

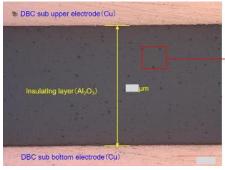
Materials

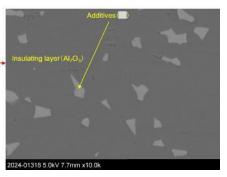
Measurement points

Module cross-sectional structure image

**Table: Module structure summary** 







**OM** image

SEM image

Module internal layout

**DBC substrate insulating layer** 



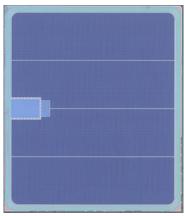
# 2. IGBT structure analysis report

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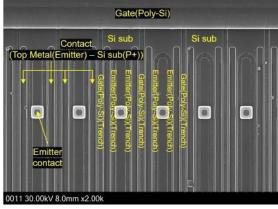
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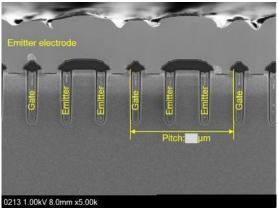
### **Excerpt from IGBT structure analysis report**



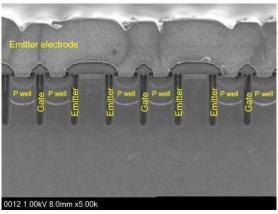
Si IGBT die (Poly-Si layer)



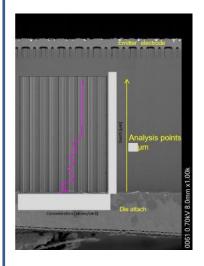
Plane SEM image of cell array (Poly-Si layer)

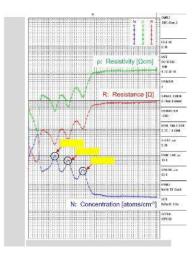


**Cross-sectional SEM image of cell array** 



<u>Cross-sectional SEM image of cell array</u> (Stain etching)





X The SR analysis results in this analysis report do not include data on the thickness and carrier concentration of the P+ Collector layer.

#### SR analysis of IGBT backside

